PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of	Docket No: Q78034
NAKAMURA, Tsuyoshi, et al.	**Continuation of 09/901,657**
Appln. No.: Not yet assigned.	Group Art Unit: Not yet assigned.
Confirmation No.: Not yet assigned.	Examiner: Not yet assigned.

Filed: October 16, 2003

For: NOVEL COPOLYMER, PHOTORESIST COMPOSITION, AND PROCESS FOR FORMING RESIST PATTERN WITH HIGH ASPECT RATIO

INFORMATION DISCLOSURE STATEMENT
UNDER 37 CFR §§ 1.97 and 1.98

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

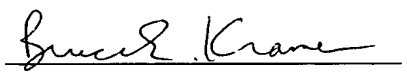
Sir:

In accordance with the duty of disclosure under 37 CFR §1.56, Applicant hereby notifies the U.S. Patent and Trademark Office of the documents which are listed on the attached PTO/SB/08 A & B (modified) form which are all the references of record in parent application No. 09/901,657. Applicant is not submitting duplicate copies of these references but requests that they be listed on the face of any patent granted on the above application. (See 37 CFR §1.98(d)). Copies of any cited copending applications, if not previously submitted, are being submitted herewith.

The submission of the listed documents is not intended as an admission that any such document constitutes prior art against the claims of the present application. Applicant does not

waive any right to take any action that would be appropriate to antedate or otherwise remove any listed document as a competent reference against the claims of the present application.

Respectfully submitted,



Bruce E. Kramer
Registration No. 33,725

SUGHRUE MION, PLLC
Telephone: (202) 293-7060
Facsimile: (202) 293-7860

WASHINGTON OFFICE
23373
CUSTOMER NUMBER

Date: October 16, 2003

Substitute for Form 1449 A & B/PTO

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(use as many sheets as necessary)

Sheet 1 of 1

Complete if Known	
Application Number	Continuation of 09/901,657
Confirmation Number	Not yet assigned.
Filing Date	October 16, 2003
First Named Inventor	NAKAMURA, Tsuyoshi
Art Unit	Not yet assigned.
Examiner Name	Not yet assigned.
Attorney Docket Number	Q78034

U.S. PATENT DOCUMENTS

Examiner Initials*	Cite No.[1]	Document Number: Number	Document Number: Kind Code[2] (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document
		US 5,234,793		08-10-1993	Sebald et al.
		US 5,234,794		08-10-1993	Sebald et al
		US 5,250,375		10-05-1993	Sebald et al
		US 6,110,637		08-29-2000	Sezi et al.
		US 2002-0031719	A1	03-2002	Nakamura et al.
		US 6,517,993	B2	02-2003	Nakamura et al.
		US 6,514,663	B1	02-2003	Hien et al.
		US 6,495,306	B2	12-2002	Uetani et al.
		US 6,165,682	A	12-2000	Foster et al.
		US 6,218,476	B1	04-2001	Coe, Stephen Wayne

FOREIGN PATENT DOCUMENTS

Examiner Initials*	Cite No.[1]	Foreign Patent Document: Country Code[3]	Foreign Patent Document: Number[4]	Foreign Patent Document: Kind Code[5] (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Translation[6]
		JP	11-212265		08-06-1999		Abstract
		JP	2001-188348	A	07-2001	MIZUTANI et al.	
		JP	2001-188349	A	07-2001	MIZUTANI et al.	

NON PATENT LITERATURE DOCUMENTS

Examiner Initials*	Cite No.[1]	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city, and/or country where published.	Translation[6]
		Sebald et al., *Chemical Amplification of Resist Lines (CARL)*, Microelectronic Engineering, pp. 531-534	

Examiner Signature		Date Considered	

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

[1]Applicant's unique citation designation number (optional). [2]See Kind Codes of USPTO Patent Documents at www.uspto.gov, MPEP 901.04 or in the comment box of this document. [3] Enter Office that issued the document, by the two-letter code (WIPO Standard ST. 3). [4]For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. [5]Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. [6] Applicant is to indicate here if English language Translation is attached.